Registration (Fax Reply)

To: ECPE e.V.

Att.: Sabrina Haberl, sabrina.haberl@ecpe.org

Please **e-mail** a scanned copy of the completed form or

send a fax to: +49 (0)911 / 81 02 88 - 28

Register before 25 August 2011

Participation fee:

O €530,- for industry

O €395,- for universities/institutes

O €120,- for students/PhDs

(shortened workshop package)

The fee includes dinner, lunch, coffee/soft drinks and a CD with the workshop presentations. A printed version of the workshop handout is available on request (≤ 42 ,–).

With the confirmation of registration you will receive the invoice. In case of cancellation after 25 August 2011 or non-attendance 50 % of the participation fee are payable.

Three participants from each ECPE member company free of charge. Allocation in sequence of registration.

Sender:

Title, given name, name

Company, department

Full address

Phone, fax

E-Mail

Date, signature

F09-030811

Organisational information

Organiser	ECPE e.V. 90443 Nuremberg, Germany www.ecpe.org
Chairman	Prof. Andreas Lindemann Otto-von-Guericke-University Magdeburg Prof. Phil A. Mawby University of Warwick DiplPhys. Thomas Harder ECPE e.V.
Organisation	Sabrina Haberl, ECPE e.V. +49 (0)911 / 81 02 88 – 13 sabrina.haberl@ecpe.org
Venue	The ICC Broad Street

Birmingham

B1 2EA

United Kingdom

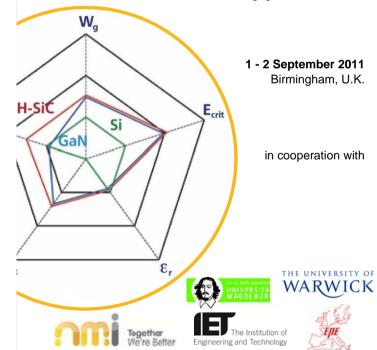


Further information (hotel list and maps) will be provided after registration.



ECPE SiC & GaN User Forum

Potential of Wide Bandgap Semiconductors in Power Electronic Applications



ECPE User Forum

SiC & GaN User Forum -Potential of Wide Bandgap Semiconductors in Power Electronic Applications

1 - 2 September 2011 Birmingham, U.K.

After the previous Silicon Carbide (SiC) or Wide Bandgap Semiconductor User Forums organised by ECPE, new power electronic systems with wide bandgap components and new devices have been reported in the areas of research and also commercially on the market. They use SiC, which in the meantime has reached a high level of maturity, or recently also GaN (Gallium Nitride) material. Time has thus come to seize on this recent development and to continue the exchange between experts involved in converter and device development:

The 4th ECPE User Forum will focus on typical power electronic systems, the use of wide bandgap semiconductors is highly promising for. Application examples will come from electric drives including converters for transportation and power supplies including inverters for renewable energy. Additionally, insights in recent SiC and GaN material and device technology - which is the base for future system development - will be given. International renowned experts have been invited to give an overview in keynotes, to in depth explain their research and development work in technical presentations and to share their knowledge in discussion forums as an indispensable part of the event.

The SiC & GaN User Forum is this way intended as a platform to share experience and ideas, to discuss and find out which power electronic systems are predestinated for usage of wide bandgap devices and how to appropriately design-in those novel, almost ideal but also challenging components.

SiC & GaN User Forum 2011 is scheduled to take place right after EPE conference 2011 in Birmingham. Prof. Andreas Lindemann (Magdeburg University, Germany) will chair the event together with Prof. Phil A. Mawby (University of Warwick) and Mr. Thomas Harder (ECPE).

Programme

Thursday, 1 September 2011		
13:30	Light Lunch	
14:00	Start of Registration	
14:30	Welcome, Opening L. Lorenz, Infineon Technologies / ECPE T. Harder, ECPE	
Introduction		
14:45	4th Wide Bandgap User Forum: Motivation and Overview A. Lindemann, Magdeburg University (D)	
SiC and GaN Power Electronic Systems		
15:00	Opportunities and Challenges for Wide Bandgap Power Devices in Megawatt Applications J. Nistor, M. Rahimo, ABB Switzerland (CH)	
15:30	Medium-Voltage High-Frequency DC-DC Converter F. Krismer, J.W. Kolar, ETH Zurich (CH)	
16:00	SiC JFETs for PV Inverters - Advantages and Challenges R. Mallwitz, SMA Solar Technology (D)	
16:30	Coffee break	
17:00	SiC Devices for High-Frequency Power Converters - an Experimental Evaluation	
	P. Ranstad, Alstom Power (S)	
17:30	P. Ranstad, Alstom Power (S) Demonstration of High Power Density Converters Using SiC devices K. Takao, Toshiba Corporation / FUPET (JP)	
17:30 18:00	Demonstration of High Power Density Converters Using SiC devices	
	Demonstration of High Power Density Converters Using SiC devices K. Takao, Toshiba Corporation / FUPET (JP) DC-DC Converters Using GaN for Collider Physics Detectors	
18:00	Demonstration of High Power Density Converters Using SiC devices K. Takao, Toshiba Corporation / FUPET (JP) DC-DC Converters Using GaN for Collider Physics Detectors S. K. Dhawan, Yale University (US) Forum System Review, Statements, Discussion Moderator: A. Lindemann	

Programme

Friday, 2 September 2011

9:00	Start of 2 nd Day
Applicati Technolo	on Aspects of High Bandgap Power Semiconductor Device pgy
9:00	R&D Activity of SiC Power Devices in Japan T. Kimoto, Kyoto University (JP)
9:45	Advances in SiC MOSFET Performance A. Agarwal, Cree (US)
10:15	Normally-On SiC JFETs Acting as Normally-Off Switches in a Module D. Domes, Infineon Technologies (D)
10:45	Coffee break
11:15	SiC BJT Devices A. Lindgren, Fairchild (S)
11:45	Reliability of Wide Bandgap Devices in Power Electronic Applications P. Mawby, University of Warwick (GB)
12:15	GaN Device Physics for Electrical Engineers N. Kaminski, University of Bremen (D)
12:45	Lunch
13:45	Recent Progress of GaN Power Devices on Si Substrates T. Nomura, Advanced Power Device Research Association (JP)
14:15	An Update on the Challenges and Opportunities of Commercializing GaN Based Power Devices A. Charles, International Rectifier (GB)
14:45	Forum Device Review, Statements, Discussion Moderator: A. Lindemann, P. Mawby Forum Experts: Previous Speakers and K. Matocha, Semisouth (US) E. Soenmez, MicroGaN (D): Efficient High-Voltage Applications Driven by GaN-on-Silicon Technology E. Hoene, FhG IZM (D): Packaging the Ideal Switch A. Schletz, FhG IISB (D): Die Attach Technologies for SiC Devices and others
	Wrap up A. Lindemann
16:00	End of Workshop